

L Number	Hits	Search Text	DB	Time stamp
15	318	438/623.ccls.	USPAT; US-PGPUB	2002/04/05 16:37
16	7010	"etch stop" or "etching stop" or "etch stopper"	USPAT; US-PGPUB	2002/04/05 17:16
17	49132	photoresist	USPAT; US-PGPUB	2002/04/05 17:16
18	643	("etch stop" or "etching stop" or "etch stopper") with photoresist	USPAT; US-PGPUB	2002/04/05 16:39
19	12	438/623.ccls. and ("etch stop" or "etching stop" or "etch stopper") with photoresist	USPAT; US-PGPUB	2002/04/05 16:41
20	44	438/623.ccls. and ("etch stop" or "etching stop" or "etch stopper") and photoresist	USPAT; US-PGPUB	2002/04/05 16:41
21	32	(438/623.ccls. and ("etch stop" or "etching stop" or "etch stopper") and photoresist) not (438/623.ccls. and ("etch stop" or "etching stop" or "etch stopper") with photoresist)	USPAT; US-PGPUB	2002/04/05 16:46
22	752	438/624.ccls.	USPAT; US-PGPUB	2002/04/05 16:46
23	52	("etch stop" or "etching stop" or "etch stopper") with photoresist and 438/624.ccls.	USPAT; US-PGPUB	2002/04/05 16:54
24	137	("etch stop" or "etching stop" or "etch stopper") and photoresist and 438/624.ccls.	USPAT; US-PGPUB	2002/04/05 16:54
25	85	("etch stop" or "etching stop" or "etch stopper") and photoresist and 438/624.ccls.) not (("etch stop" or "etching stop" or "etch stopper") with photoresist) and 438/624.ccls.)	USPAT; US-PGPUB	2002/04/05 16:55
26	39	((("etch stop" or "etching stop" or "etch stopper") and photoresist and 438/624.ccls.) not ((("etch stop" or "etching stop" or "etch stopper") with photoresist) and 438/624.ccls.)) and damascene	USPAT; US-PGPUB	2002/04/05 16:59
27	223	438/634.ccls.	USPAT; US-PGPUB	2002/04/05 17:00
28	56	("etch stop" or "etching stop" or "etch stopper") with photoresist and 438/634.ccls.	USPAT; US-PGPUB	2002/04/05 17:05
29	308	438/638.ccls.	USPAT; US-PGPUB	2002/04/05 17:05
30	47	("etch stop" or "etching stop" or "etch stopper") with photoresist and 438/638.ccls.	USPAT; US-PGPUB	2002/04/05 17:09
31	1049	438/637.ccls.	USPAT; US-PGPUB	2002/04/05 17:10
32	84	("etch stop" or "etching stop" or "etch stopper") with photoresist and 438/637.ccls.	USPAT; US-PGPUB	2002/04/05 17:13
33	362	438/725.ccls.	USPAT; US-PGPUB	2002/04/05 17:13
34	14	("etch stop" or "etching stop" or "etch stopper") with photoresist and 438/725.ccls.	USPAT; US-PGPUB	2002/04/05 17:14
35	106	438/952.ccls.	USPAT; US-PGPUB	2002/04/05 17:15
36	3	("etch stop" or "etching stop" or "etch stopper") with photoresist and 438/952.ccls.	USPAT; US-PGPUB	2002/04/05 17:15
37	1191	438/for.355.ccls.	EPO; JPO; DERWENT	2002/04/05 17:16
38	3084	"etch stop" or "etching stop" or "etch stopper"	EPO; JPO; DERWENT	2002/04/05 17:16
39	44654	photoresist	EPO; JPO; DERWENT	2002/04/05 17:16
40	3	438/for.355.ccls. and ("etch stop" or "etching stop" or "etch stopper")	EPO; JPO; DERWENT	2002/04/05 17:16
41	1006	damascene	EPO; JPO; DERWENT	2002/04/05 17:16
42	0	438/for.355.ccls. and damascene	EPO; JPO; DERWENT	2002/04/05 17:16
44	272	438/for.489.ccls.	EPO; JPO; DERWENT	2002/04/05 17:17
45	0	damascene and 438/for.489.ccls.	EPO; JPO; DERWENT	2002/04/05 17:17

46	0	((("etch stop" or "etching stop" or "etch stopper") with photoresist) and 438/634.ccls.) and 438/for.489.ccls.	EPO; JPO; DERWENT	2002/04/05 17:17
47	46	("etch stop" or "etching stop" or "etch stopper") and photoresist and damascene	EPO; JPO; DERWENT	2002/04/05 17:17
-	1	("6140226").PN.	USPAT;	2002/04/04 15:49
-	1	("6077769").PN.	US-PGPUB	2002/04/04 15:50
-	484800	organic or polytetrafluoroethylene or "fluorinated polyallyl ether" or "fluorinated polyimide"	USPAT;	2002/04/04 15:52
-	513	(438/618).CCLS.	US-PGPUB	2002/04/04 15:53
-	125	(organic or polytetrafluoroethylene or "fluorinated polyallyl ether" or "fluorinated polyimide") and ((438/618).CCLS.)	USPAT;	2002/04/04 15:53
-	5782	"etch stop"	US-PGPUB	2002/04/04 15:53
-	29	((organic or polytetrafluoroethylene or "fluorinated polyallyl ether" or "fluorinated polyimide") and ((438/618).CCLS.)) and "etch stop"	USPAT;	2002/04/04 15:53
-	318	438/623.ccls.	US-PGPUB	2002/04/04 16:10
-	1266	(organic or polytetrafluoroethylene or "fluorinated polyallyl ether" or "fluorinated polyimide") and "etch stop"	USPAT;	2002/04/04 16:10
-	31	438/623.ccls. and ((organic or polytetrafluoroethylene or "fluorinated polyallyl ether" or "fluorinated polyimide") and "etch stop")	US-PGPUB	2002/04/04 16:10